

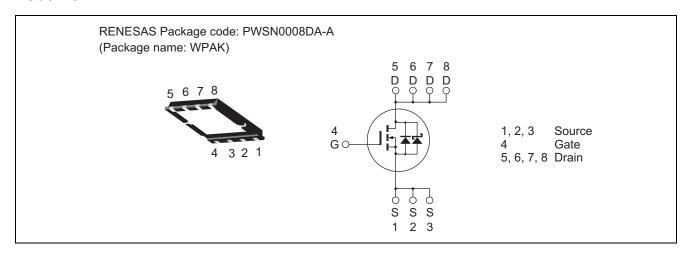
RJK0381DPA

Silicon N Channel Power MOS FET with Schottky Barrier Diode Power Switching REJ03G1829-0200 Rev.2.00 Sep 29, 2009

Features

- High speed switching
- Capable of 4.5 V gate drive
- Low drive current
- High density mounting
- Low on-resistance $R_{DS(on)} = 3.4 \text{ m}\Omega \text{ typ. (at } V_{GS} = 10 \text{ V)}$
- Pb-free
- Halogen-free

Outline



Absolute Maximum Ratings

 $(Ta = 25^{\circ}C)$

Item	Symbol	Ratings	Unit
Drain to source voltage	V _{DSS}	30	V
Gate to source voltage	V _{GSS}	±20	V
Drain current	I _D	40	Α
Drain peak current	I _{D(pulse)} Note1	160	Α
Body-drain diode reverse drain current	I _{DR}	40	Α
Avalanche current	I _{AP} Note 2	17	Α
Avalanche energy	E _{AR} Note 2	28.9	mJ
Channel dissipation	Pch Note3	45	W
Channel to Case Thermal Resistance	θch-C	2.78	°C/W
Channel temperature	Tch	150	°C
Storage temperature	Tstg	-55 to +150	°C

Notes: 1. PW \leq 10 μ s, duty cycle \leq 1%

- 2. Value at Tch = 25°C, Rg \geq 50 Ω
- 3. Tc = 25°C

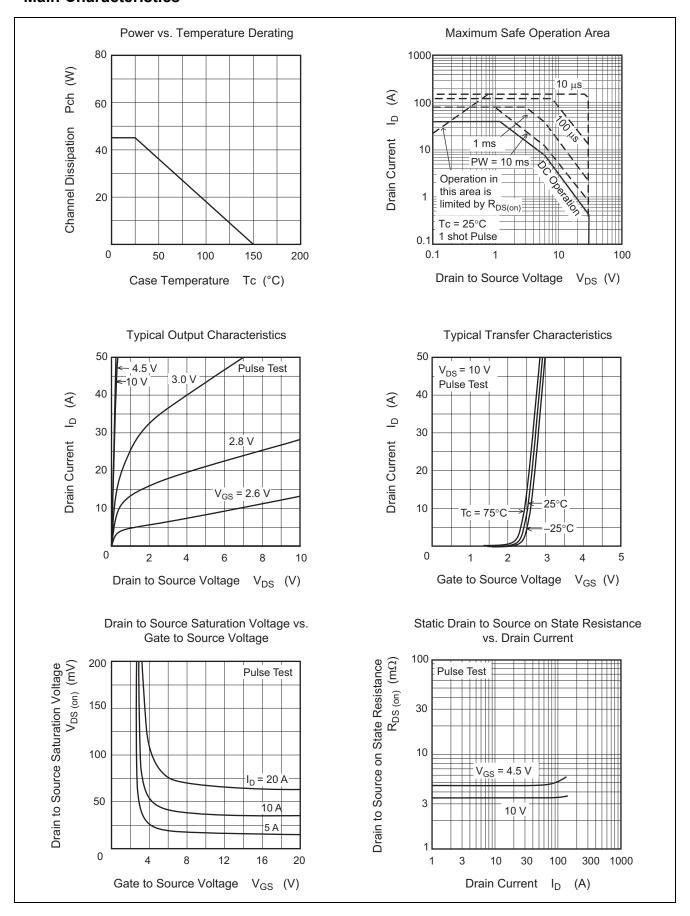
Electrical Characteristics

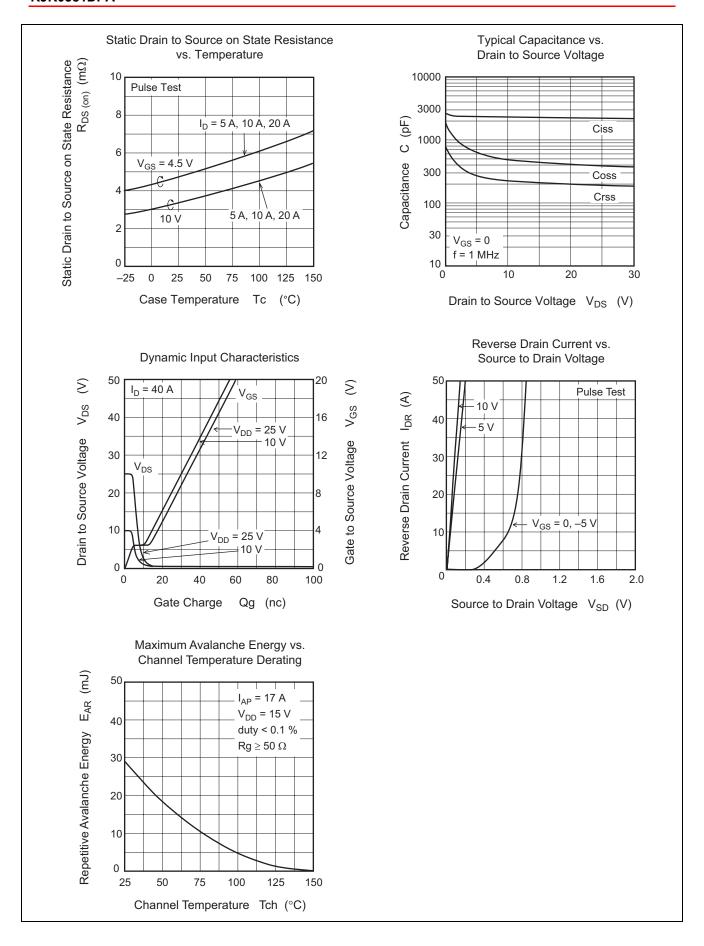
 $(Ta = 25^{\circ}C)$

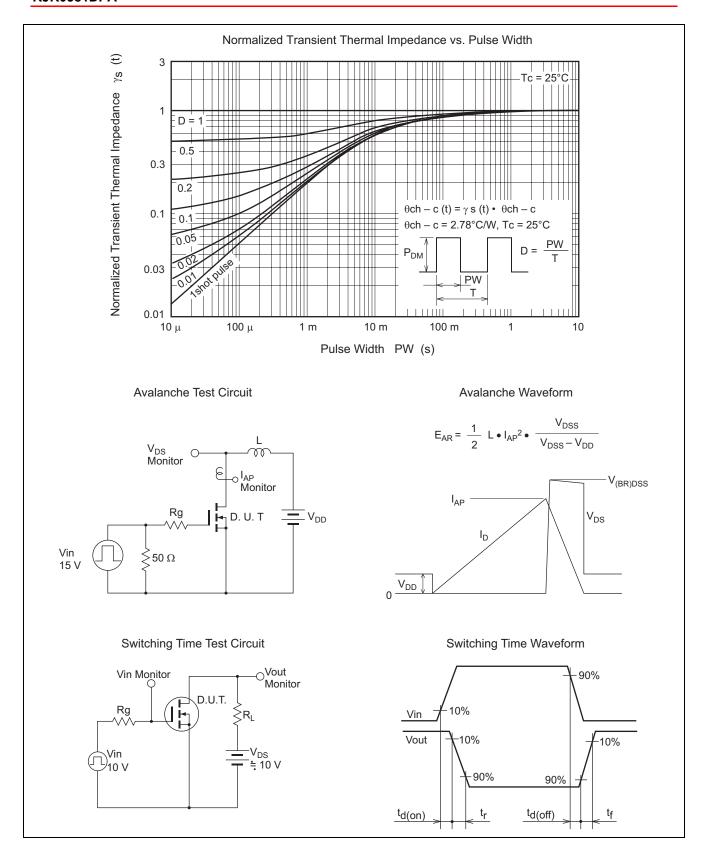
Item	Symbol	Min	Тур	Max	Unit	Test Conditions
Drain to source breakdown	V _{(BR)DSS}	30	_	_	V	I _D = 10 mA, V _{GS} = 0
voltage						
Gate to source leak current	I _{GSS}		_	±0.1	μΑ	$V_{GS} = \pm 20 \text{ V}, V_{DS} = 0$
Zero gate voltage drain current	I _{DSS}	l	_	1	m A	$V_{DS} = 30 \text{ V}, V_{GS} = 0$
Gate to source cutoff voltage	$V_{GS(off)}$	1.2	_	2.5	V	$V_{DS} = 10 \text{ V}, I_{D} = 1 \text{ mA}$
Static drain to source on state	R _{DS(on)}	_	3.4	4.5	mΩ	$I_D = 20 \text{ A}, V_{GS} = 10 \text{ V}^{\text{Note4}}$
resistance	R _{DS(on)}	_	4.7	6.6	mΩ	$I_D = 20 \text{ A}, V_{GS} = 4.5 \text{ V}^{\text{Note4}}$
Forward transfer admittance	y _{fs}		78	_	S	I _D = 20 A, V _{DS} = 10 V ^{Note4}
Input capacitance	Ciss		2200	_	pF	V _{DS} = 10 V, V _{GS} = 0,
Output capacitance	Coss		490	_	pF	f = 1 MHz
Reverse transfer capacitance	Crss	_	225	_	pF	
Gate Resistance	Rg	-	2.3	_	Ω	
Total gate charge	Qg	-	15	_	nC	$V_{DD} = 10 \text{ V}, V_{GS} = 4.5 \text{ V},$
Gate to source charge	Qgs	-	6.2	_	nC	I _D = 40 A
Gate to drain charge	Qgd	-	4.3	_	nC	
Turn-on delay time	t _{d(on)}	-	11	_	ns	V _{GS} = 10 V, I _D = 20 A,
Rise time	t _r	_	15	_	ns	$V_{DD}\cong 10~V,~R_L=0.5~\Omega, \\ Rg=4.7~\Omega$
Turn-off delay time	$t_{d(off)}$	_	49	_	ns	
Fall time	t _f	_	10	_	ns	
Body-drain diode forward voltage	V_{DF}	_	0.40	_	V	$I_F = 2 A, V_{GS} = 0^{Note4}$
Body-drain diode reverse	t _{rr}	_	21	_	ns	I _F = 40 A, V _{GS} = 0
recovery time						di _F / dt = 100 A/ μs

Notes: 4. Pulse test

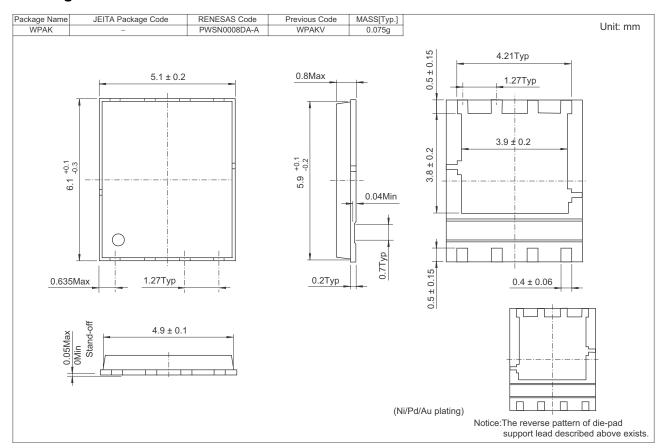
Main Characteristics







Package Dimensions



Ordering Information

Part No.	Quantity	Shipping Container
RJK0381DPA-00-J53	3000 pcs	Taping

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